Ferromagnetism and increased ionicity in epitaxially grown TbMnO3 films

Published in:
Physical Review. B: Condensed Matter and Materials Physics

DOI:
10.1103/PhysRevB.79.014416

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Document Version
Publisher's PDF, also known as Version of record

Publication date:
2009

Link to publication in University of Groningen/UMCG research database

Citation for published version (APA):

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I. INTRODUCTION

Orthorhombic TbMnO$_3$ is a multiferroic,\cite{1,2} that is, it displays both antiferromagnetic and ferroelectric orders at low temperatures.\cite{3,4} Moreover, these two ferroic orderings are so strongly coupled that the electrical polarization can be flipped by a magnetic field. This large magnetoelectric (ME) coupling has recently made of TbMnO$_3$ a very popular material. However, films of orthorhombic TbMnO$_3$ have seldom been reported.

From a fundamental viewpoint, a main advantage of using thin films of TbMnO$_3$ is the possibility of modifying the structure using the strain imposed by the substrate. This approach should allow for extra degrees of freedom compared to the well-established method of changing the Mn-O-Mn bond angle by rare-earth substitution and should shed light into the structural details that determine the magnetic and ferroelectric behaviors. On the application side, thin films of TbMnO$_3$ are also of clear interest where integration and miniaturization are required. Moreover, the possibility of tuning the exchange interactions and inducing ferromagnetic behavior via strain could lead to single-phase ferromagnetic ferroelectrics, which are highly interesting for applications and are very scarce.\cite{1}

Bulk TbMnO$_3$ (TMO) displays a complex magnetic behavior. A first antiferromagnetic transition takes place at $T_N \sim 40$ K, where Mn spins order in a sinusoidal incommensurate structure. As the temperature is further decreased, the propagation vector of the sinusoidal structure is reduced until it locks at $T_{\text{lock}} \sim 28$ K, where the magnetic structure changes to a spiral antiferromagnetic ordering. A spontaneous electrical polarization ($P_s$) along the $c$ axis and a strong ME effect are observed below $T_{\text{lock}}$.\cite{5} Using symmetry considerations, Kenzelman \textit{et al.}\cite{6} and Mostovoy\cite{7} showed that a $P_s$ must exist in any spiral magnet. Due to this direct relationship between the magnetic structure and $P_s$, the ME coupling in these materials is very strong. An electronic origin was originally reported to explain the ferroelectric polarization observed in TbMnO$_3$.\cite{8} However, Sergienko and Dagotto\cite{9} proposed that the Dzyaloshinskii-Moriya interaction is the microscopic mechanism responsible for such effect. Malashevich and Vanderbilt\cite{10} and Xiang \textit{et al.}\cite{11} recently confirmed that ionic displacements are indeed at the origin of the ferroelectricity in this material.

The few existing reports on thin films of orthorhombic TbMnO$_3$ are on relatively thick (relaxed) films, for which epitaxial strain does not play a clear role.\cite{12,13} Here we have used epitaxial strain to modify the structure of TbMnO$_3$. This has been done by growing the films with small enough thicknesses on SrTiO$_3$ substrates. We show that the strained films indeed differ substantially from their bulk counter parts. The films display ferromagneticlike interactions below the bulk Néel temperature. Moreover, an increased x-ray photoemission spectroscopy (XPS) Mn 3s splitting is observed, which is found to be directly related to an increase in the ionicity of the films with respect to the bulk structure.

II. EXPERIMENTAL

(001)-oriented TbMnO$_3$ (TMO) thin films were deposited on atomically flat TiO$_2$-terminated (001)-SrTiO$_3$ (STO) cubic substrates by pulsed laser deposition. The TMO deposition was performed at 750 °C at oxygen pressures ranging from 0.25 to 0.9 mbar. Structural characterization, including high-resolution synchrotron measurements, shows that the thin films have a distorted perovskite structure free from secondary phases.\cite{13} The thin films are clamped to the substrate along one of the in-plane [100] directions while they maintain an orthorhombic structure, as shown in Fig. 1(a). This results in that despite the partial clamping, the films are strained along both pseudocubic directions. The four equivalent orientational domains, all with the $c$-axis out of plane, are present so that the films keep the fourfold macroscopic symmetry of the substrate [see Fig. 1(b)].

III. RESULTS AND DISCUSSION

Figure 2(a) shows the orthorhombic cell parameters for films of different thicknesses grown under an oxygen pressure of 0.9 mbar, as obtained by x-ray diffraction area maps of the reciprocal space around the (113) and (103) substrate reflections. In Fig. 2(b), the corresponding pseudocubic lattice parameters are plotted. In this figure it is clearly seen that the strained films share the pseudocubic lattice param-
Slightly expanded $a_o$ axis. The out-of-plane $c_o$ lattice parameter is enlarged in the films consistent with an overall compressive in-plane strain.

Upon increasing thickness ($d$) the structure changes in an unconventional way. The out-of-plane cell parameter $c_o$ remains constant with thickness, indicating that the strain remains constant. The orthorhombic distortion increases while $a_o$ decreases approaching the bulk value. At the same time $b_o$ increases; but, unlike $a_o$, it approaches a value substantially smaller than that of the bulk. This gradual change is maintained at least until $d=60$ nm, and at $d=80$ nm part of the film undergoes a sudden relaxation to the bulk structure [14] [dashed lines in Fig. 2(a)]. The crystal structure of the films grown at 0.25 mbar shows the same trend but slightly larger $c_o$, which is likely due to the presence of oxygen vacancies. [13] The presence of oxygen vacancies in the films grown at 0.9 mbar is unlikely since the bulk unit cell is reproduced for the relaxed samples.

Figure 3(a) shows the magnetization as a function of temperature for a 40-nm-TMO film grown at 0.9 mbar measured under zero-field-cooling (ZFC) and field-cooling (FC) conditions. The magnetization presents an upturn at $T^* \sim 40$ K. This feature can be better appreciated in the evolution of the inverse susceptibility ($\chi^{-1}$) with temperature [Fig. 3(b)], where a change in slope can be seen at $T^*$. The modeling of the high-temperature tail of Fig. 3(b) by means of a Curie-Weiss law gives a negative extrapolated temperature ($\theta_W \sim -150$ K), indicating that the dominant magnetic interaction is antiferromagnetic. This suggests that the transition
observed at $T^*$ is ferromagnetic-like. The splitting at low temperatures between FC and ZFC measurements typical of a glassy behavior indicates that ferromagnetic interactions are present in the films. Figure 3(c) shows magnetization loops measured at 10, 25, and 50 K and confirms the presence of ferromagnetism. Figure 3(d) depicts the evolution of the saturation magnetization ($M_s$) as a function of temperature, showing that ferromagnetism develops below $T^*$ $\sim 40$ K. Similar effects have recently been observed in orthorhombic YbMnO$_3$ and YMnO$_3$ thin films, which points toward a general mechanism in manganite thin films.

We notice that the observed magnetic ordering temperature ($\sim 40$ K) is very close to the transition temperature to the sinusoidal antiferromagnetic structure in the bulk compound; however, the weak ferromagnetism appearing in our films has no counterpart in bulk. Moreover, our magnetic measurements did not reveal any feature related to the stabilization of the spiral antiferromagnetic ordering and the concomitant onset of ferroelectricity. Special attention should be paid to the possible existence of Mn$_3$O$_4$ impurities (even though we were unable to observe them by x-ray diffraction), which could account for the presence of ferromagnetism at low temperatures. However, the measured ferromagnetic saturation ($M_s$) $\sim 1.5\mu_B$/f.u. at 10 K) is higher that the saturation magnetization expected for Mn$_3$O$_4$, with $M_s \sim 0.5\mu_B$/Mn, strongly indicating that the latter cannot account for the observed ferromagnetism. The magnetic characterization corresponding to films with different thickness and grown at very different oxygen pressures (0.25 and 0.9 mbar) displayed analogous results.

Figure 4(a) shows the XPS spectra at the Mn 3s edge corresponding to films grown at oxygen pressures of 0.25 and 0.9 mbar. The Mn 3s level splitting originates in the intra-atomic exchange coupling between 3s and 3d electrons and the magnitude of the splitting is reported to increase linearly as the local ionic Mn valence decreases. The maximum experimental values reported for Mn ions with a 3+ nominal valence is 5.3 eV. Figure 4(a) shows that in our films the splitting is 5.7(1) eV. This value is independent of the thickness and the oxygen pressure during growth. It can be suggested that the enlarged splitting is due to a mixed $+2/+3$ valence that could be originated by oxygen vacancies (a likely defect in these compounds). However, the absence of shake-up peaks in the Mn 2p spectra [see Fig. 4(b)] goes against the presence of Mn$^{2+}$ in the films. Moreover, the splitting remains the same (within the accuracy of the setup) no matter the oxygen growth pressure. The presence of oxygen vacancies has thus no noticeable influence in the observed splitting.

Therefore, the increased Mn 3s splitting in the films should be explained in terms of a more complex scenario. In order to shed light into this problem we have performed configuration-interaction (CI) calculations within the embedded-cluster approach. The electronic structure of an MnO$_6$ cluster is calculated with accurate quantum chemical schemes that ensure a precise and unbiased treatment of the strong electron correlation effects present in this type of materials. This MnO$_6$ cluster is embedded in a set of point charges that reproduce the Madelung potential in the cluster region due to the rest of the crystal. To avoid an artificial delocalization of the cluster electrons to the point charges, the centers nearest to the cluster are represented with model potentials that account for the Coulomb and exchange interactions between the electrons in the cluster and the surroundings. This local approach has been successfully applied in the past to interpret XPS spectra of various ionic transition metal oxides.

The final states responsible for the two peaks in the Mn 3s XPS spectrum are characterized by a $3s^23p^63d^6$ electronic configuration. Only taking into account this configuration, very large exchange splittings are obtained in the calculations. However, it was shown by Bagus et al. in the analysis of the exchange splitting in MnO that important contributions to the wave function arise from $3s^23p^13d^5$ electronic configurations. Semiquantitative agreement with experiment can be obtained by also including the $3s^23p^23d^4f^2$ configurations. Applying this strategy to embedded MnO$_6$ clusters representing MnO, LaMnO$_3$, and CaMnO$_3$ gives exchange splittings of 6.38, 5.72, and 3.95 eV, respectively. These calculated values are in good agreement with the following experimental numbers: 6.2 eV for MnO, 5.3 eV for LaMnO$_3$, and 4.0 eV for CaMnO$_3$.

The embedded cluster for bulk TbMnO$_3$ was constructed using the experimental structure. For the thin-film cluster, we applied the lattice parameters of the thinnest film reported in Fig. 2(a). The calculations give an exchange splitting of 5.18 eV for bulk TbMnO$_3$ and 5.46 eV for the thin film. The slight underestimation in comparison to the experimental value of 5.7 eV reported in Fig. 4(a) is to be expected be-
cause in the calculations, the 4f-type expansion functions were not optimized. The increase of +0.3 eV in comparison to bulk is precisely what is observed in the experiment.

The steady increase in the exchange splitting from CaMnO₃ to LaMnO₃ to MnO suggests that the exchange splitting is determined by the formal ionic Mn charge as reported by Galakhov et al. However, this relationship cannot be used to explain the different exchange splitting in bulk and thin film TbMnO₃, since in both cases the formal Mn charge is the same. Actually the calculated Mn charge is slightly smaller in the bulk than in the thin film contradicting the suggested relationship between Mn charge and exchange splitting. Serious doubts have been raised on the usefulness of the concept of the formal charge and/or oxidation state to interpret the electronic structure of transition-metal compounds. Instead, we analyze the relation between the exchange splitting and the screening of the core hole by the oxygen ligands. For this purpose, the N-electron wave function is expressed in localized orbitals and configurations are grouped by noncharge transfer (Mn 3d⁶), charge transfer (CT) (Mn 3d⁶L⁻¹), and configurations with two or more electrons transferred from oxygen to Mn. This analysis shows that the screening of the core hole by the oxygens is more effective in the bulk than in the film; the CT configurations have a larger weight in the wave function of the bulk cluster (44%) than in the film (38%). Hence, instead of the formal Mn charge, the exchange splitting is determined by the degree of oxygen screening. It is well known that MnO is highly ionic with almost no charge transfer in the wave function, while CaMnO₃ has a more covalent character with a much larger degree of screening, in line with the observed exchange splittings.

The reduced degree of core hole screening by the oxygens in the films is related to the shorter Mn-O distances in the ab plane. These shorter distances make the oxygen-to-metal charge-transfer configuration lies higher in energy and contributes less to the wave function. In a one-electron reasoning this can be explained by the fact that shorter Mn-O distances lead to enhanced antibonding interactions, which increase the Mn 3d orbital energies. This causes a higher charge-transfer energy and, hence, less effective ligand screening.

IV. CONCLUDING REMARKS

It is tempting to say that the decreased charge transfer in the films reduces the efficiency of the superexchange mechanism and enhances ferromagnetism with respect to the bulk case, in agreement with our experimental observations. However, given the subtle competition between ferromagnetic and antiferromagnetic exchange constants in this material and the likely influence of the Tb ions, a more complex analysis of the magnetic structure of the films is needed to explain the observed ferromagnetism. For that the full structure determination of the films, including the oxygen atomic positions, is compulsory.

Another possible origin of the observed ferromagnetism is the coupling between magnetization and strain. In this respect, there is an analogy between the induction of ferromagnetism in epitaxial antiferromagnets and the well-known induced ferroelectricity in incipient ferroelectrics. Indeed, antiferromagnets are piezomagnetics and the epitaxial strain should induce a magnetic moment in the films. Moreover, the linear part of the magnetostriction in antiferromagnets is usually several orders of magnitude larger. The strong coupling of the magnetic structure of TbMnO₃ to the lattice has recently demonstrated. In our films, the epitaxial stress is estimated to be 2 × 10⁴ N/m² [using a value of the Young modulus of 20 GPa (Ref. 31)] and, thus, the magnetization values observed are compatible with an effective piezomagnetic coefficient of 10⁻¹⁰ m/A. This value is substantially smaller than the reported magnetostriction bulk values and one order of magnitude larger than typical intrinsic piezomagnetic coefficients in antiferromagnets. In addition, the presence of in-plane domains in the films also makes it difficult to extract any final conclusions from the data currently available.

In summary, TbMnO₃ films grown epitaxially on SrTiO₃ substrates display a strained orthorhombic perovskite structure less distorted than that of the bulk. This structural modification gives rise to an increased ionicity in the films and to very different magnetic properties. The films show ferromagnetism below ~40 K and do not display signs of a second low-temperature magnetic transition, as the one associated to the onset of ferroelectricity in bulk TbMnO₃.

ACKNOWLEDGMENTS

The authors are grateful to G. Catalan, J. Fontcuberta, X. Martí, M. Mostovoy, and T. T. M. Palstra for very useful discussions. They would like to thank T. F. Landaluce and P. Rudolf for the assistance with and access to the XPS measurements. This work was supported by the EU STREP MaCoMuFi (Contract No. FP6-NMP3-CT-2006-033221) and the Spanish Ministry of Science (Grant No. CTQU2005-08459-C02-02/BQU).

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PHYSICAL REVIEW B 79, 014416 (2009)